MARKED-UP VERSION OF ENGLISH TRANSLATION OF INTERNATIONAL APPLICATION AS ORIGINALLY FILED

DESCRIPTION

Attorney Docket No. 36856.1429

DUPLEXER AND COMMUNICATION DEVICE

Technical BACKGROUND OF THE INVENTION

1. Field of the Invention

______The present invention relates to a duplexer and a communication device which are used in communications equipment, and more particularly, to a duplexer and a communication device which that are provided with a band filter formed by connecting a including a plurality of surface acoustic wave resonators to construct that define a ladder circuit.

Background2. Description of the Related Art

 power resistance is strenglyhighly desired for the surface acoustic wave element.

[0003] _____Japanese Unexamined Patent Application Publication No. 2002-353768 (Patent Document 1) described below discloses a surface acoustic wave element with-having increased electric power resistance. Here, on On a 64° Y-Xcut LiNbO3 substrate, an IDT electrode is formed by laminating a Ti foundation electrode layer formed through epitaxial growth and an Al electrode layer formed further through epitaxial growth on the Ti foundation electrode layer. The (111) face of the crystal of the Al electrode layer, the (001) face or (100) face of the crystal of the Ti foundation electrode layer, and the (001) face of an LiTaO3 substrate are aligned in parallel, whereby it has been considered that the electric power resistance is increased. [0004] ——On the other hand, in a duplexer used for a mobile phone based on the W-CDMA system, a plurality of surface acoustic wave elements are connected to constructdefine a reception-side band filter and a transmission-side band filter. Fig. 20 shows an example of such a related-art duplexer circuit. In Fig. 20, an area surrounded by a dashed line constructs defines a duplexer 201. The duplexer 201 includes an antenna terminal 201a. The antenna terminal 201a is connected to an antenna 202. Furthermore, an external inductance 203 and an external

capacitor 204 are connected between the antenna terminal 201a and the antenna 202. To be specificSpecifically, the inductance 203 is inserted between the antenna terminal 201a and the antenna 202 and the capacitor 204 is connected between a connection point between the antenna 202 and the inductance 203 and a ground potential.

[0005] Meanwhile, the The duplexer 201 includes a transmission-side band filter 201A and a reception-side band filter 201B. In the transmission-side band filter 201A, a plurality of serial arm resonators Sa to Sc and parallel arm resonators Pa and Pb are connected to constructdefine a ladder circuit. Herein, anAn inductance element 205 is connected in parallel with respect to the serial arm resonator Sc in the last pole. Also, in the reception-side band filter 201B-as well, a plurality of serial arm resonators Sd to Sf are connected to a plurality of parallel arm resonators Pc and Pd to achievedefine a ladder circuit. Herein, anAn inductance element 206 is connected in parallel with respect to the serial arm resonator Se in the center. [0006] ——Furthermore, inductance elements 207 and 208 are connected between the parallel arm resonators Pa and Pb of the transmission-side band filter and the ground potential.

Patent Document 1: Japanese Unexamined Patent Application
Publication No. 2002-353768

Disclosure of Invention

[0007] ____With the surface acoustic wave element having the electrode construction described in Patent Document 1, the electric power resistance can be increased as described above. However, when the surface acoustic wave elements described in Patent Document 1 are used for the serial arm resonators Sa to Sc, the parallel arm resonators Pa and Pb, the serial arm resonators Sd to Sf, and the parallel arm resonators Pc and Pd of the duplexer 201 shown in Fig. 20, the electric power resistance is increased, but it is revealed that an out-of-band attenuation is not sufficient and also an isolation characteristic is not satisfactory. This will be described with reference to Figs. 21 to 23. [0008] ——The surface acoustic wave elements having the electrode construction described in Patent Document 1 are used for the serial arm resonators Sa to Sc and Sd to Sf, and the parallel arm resonators Pa to Pd, and a 64° rotated, Y-cut LiNbO3 substrate is used to fabricatein the duplexer 201. Fig. 21 shows a frequency characteristic of the transmission-side band filter 201A, and Fig. 22 shows a frequency characteristic of the reception-side band filter 201B. It should be noted that curved lines on the lower side of Figs. 21 and 22 represent the frequency characteristics in pass bands shown through magnification of the corresponding frequency characteristics. Then, Fig. 23 shows an isolation characteristic of the duplexer 201. [0009] ——In the duplexer of the mobile phone based on the W-CDMA method, the attenuation in the outer neighborhoodvicinity of the pass band on the high pass side of 1920 MHz to 1980 MHz, namely, in the pass band of the reception-side band filter, is required to be at least about 40 dB. In view of the above, in the transmission-side band filter 201A shown in Fig. 20, by connecting the inductance 205 to the serial arm resonator Sc, an insertion loss is sacrificed to provide an attenuation pole on the outer side of the high pass in the bass band, thereby achieving the increase in the attenuation. However, as is apparent from Fig. 21, even when the above-mentioned attenuation pole is formed provided, the attenuation on the outer side of the high pass in the bass band has managed to is merely satisfyabout 40 dB. [0010] ——Furthermore, as shown in Fig. 23, the isolation characteristic in 2110 MHz to 2170 MHz corresponding to the reception-side pass band is merely about 40 dB as well. On the other hand, the characteristics of the duplexer 201 vary depending on the temperature. Therefore, it-is understood that-the attenuation in the reception-side pass band cannot be reliably kept-maintained

to be equal to or larger greater than 40 dB over the

temperature range where—in which the duplexer 201 is used.

— In view of the above—

SUMMARY OF THE INVENTION

circumstances, it is an objectabove, preferred embodiments of the present invention to provide a duplexer constructed by using including a plurality of surface acoustic wave elements in which not only the electric power resistance can be increased but also the out-of-band attenuation and the isolation characteristic can be set to a satisfactorily large value, and also relates to a communication device using including the duplexer.

The present invention relates to a A duplexer, including a according to a preferred embodiment of the present invention includes a transmission-side band filter and a reception-side band filter respectively constructed by connecting including a plurality of surface acoustic wave resonators connected together to formdefine a ladder circuit, characterized in that. Each of the surface acoustic wave reconators includes a 47° to 58° rotated, Y-cut, X-propagating LiNbO3 substrate and an IDT electrode formedprovided on the LiNbO3 substrate, that the. The IDT electrode includes a Ti foundation electrode layer formedprovided on the LiNbO3 substrate and an Al electrode layer formedprovided on the Ti foundation electrode layer.

and that a. A (111) face of the Al electrode layer, a (001) face or (100) face of the Ti foundation electrode layer, and a (001) face of the LiNbO₃ substrate are aligned in parallel.

[0013] According to a particular aspect of the duplexer in accordance with the present inventionPreferably, the Ti foundation electrode layer is formed through epitaxial growth on the LiNbO₃ substrate and the Al electrode layer is formed through epitaxial growth on the Ti foundation electrode layer.

According to another particular aspect of the duplexer in accordance with the present invention, in In the reception-side band filter, a first inductance is inserteddisposed in parallel with respect to at least one serial arm resonator connected to a serial arm of the ladder circuit among the plurality of surface acoustic wave resonators, and in the transmission-side band filter, a second inductance is inserteddisposed between a parallel arm resonator connected to a parallel arm of the ladder circuit among the plurality of surface acoustic wave resonators and a ground potential.

[0014] According to another particular aspect of the duplexer in accordance with the present invention, it is characterized in that the The first inductance and the second inductance are respectively constructed by at least one of a wire bonding used for electrical connection

in the duplexer, a line embedded in the duplexer, and an external coil partcomponent.

[0015] ---- A communication device according to the present invention includes the duplexer constructed on the basis of the present invention, another preferred embodiment of the present invention includes the duplexer as described above, in which the duplexer includes an antennal terminal, a third inductance is inserted between the antennal terminal and the antenna, and the duplexer further includes a capacitor connected between a connection point between the third inductance and the antennal and the ground potential. [0016] — The In the duplexer according to preferred embodiments of the present invention-includes, the transmission-side band filter constructed by connecting theincludes a plurality of surface acoustic wave resonators which are connected to formdefine a ladder circuit and the reception-side band filter constructed by connecting the includes a plurality of surface acoustic wave resonators which are connected to formdefine a ladder circuit. Then, each of the surface acoustic wave resonators hasincludes the Ti foundation electrode layer formedprovided on the LiNbO3 substrate and the Al electrode layer formedprovided on the Ti foundation electrode laver, and the (111) face of the Al electrode layer, the (001) face or (100) face of the Ti foundation electrode layer, and the (001) face of the LiNbO3

substrate are aligned in parallel. Thus, each of the surface acoustic wave resonators has a sufficient electric power resistance. Therefore, the electric power resistance of the duplexer can be is increased.

Moreover, the 47° to 58° rotated, Y-cut, X-propagating LiNbO₃ substrate is used, and as is apparent from experiments to be described later, not only the electric power resistance ean be is increased, but also, the attenuation on the high pass side of the pass band ean be is set to have a sufficiently large value. At the same time, it is possible to effectively improve the isolation characteristic—as well

<u>——As a result, according to preferred</u>
<u>embodiments of</u> the present invention, for example, it is
possible to provide the duplexer which is suitably used as
the duplexer <u>efin</u> the mobile phone based on the W-CDMA
method, <u>which</u> is superior in the electric power resistance,
and <u>which</u> has <u>the</u>—large attenuation and isolation
characteristics.

_____Preferably, the Ti foundation electrode layer and the Al electrode layer are formed through epitaxial growth, and in that ease, the (111) face of the Al electrode layer and the (001) face or (100) face Ti foundation electrode layer are aligned in parallel with respect to the (001) face of LiNbO₁ substrate.

[0021] ——When the first inductance inserted in parallel with respect to the serial arm resonator of the receptionside band filter and the second inductance between the parallel arm resonator of the transmission-side band filter and the ground potential are respectively constructed defined by at least one of the wire bonding wire bonding used for electrical connection in the duplexer, the line embedded in the duplexer, and the external coil part, it is possible to construct the first and second inductances without the necessity of providing external parts components or other parts.additional components. Therefore, the duplexer according to preferred embodiments of the present invention ean be provided without causing the does not increase in the number of parts of components required for the duplexer. [0022] ——The communication device according to another preferred embodiment of the present invention hasincludes

the duplexer emetrueted on the basis according to various preferred embodiments of the present invention, the third inductance is inserted between the antenna terminal and the antenna, and the capacitor is connected between a connection point between the third inductance and the antenna and the ground potential. Therefore, it is possible to effectively improve—the attenuation outside the pass band and the isolation characteristic are effectively improved.

[0023] Other features, elements, steps, characteristics and advantages of the present invention will become more apparent from the following detailed description of preferred embodiments of the present invention with reference to the attached drawings.

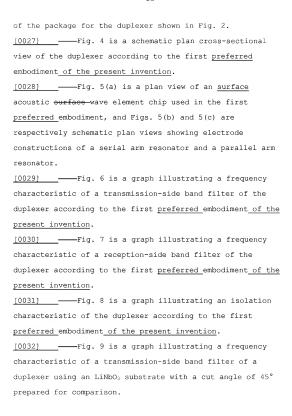
BRIEF DESCRIPTION OF THE DRAWINGS

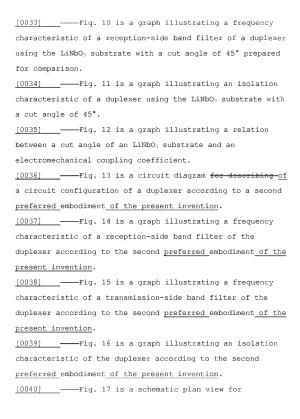
[0024] ——Fig. 1(a) is a circuit diagram fer

describingof a circuit configuration of a duplexer according
to a first preferred embodiment of the present invention,
and Fig. 1(b) is a partially notched frontal cross-sectional
view showing a construction of an IDT electrode.

[0025] ——Fig. 2 is a schematic plan view showing a
specific configuration of the duplexer according to the
first preferred embodiment of the present invention.

[0026] ——Fig. 3 is a schematic plan cross-sectional
view of a positional construction at an intermediate height





describing a specific configuration of the duplexer according to the second preferred embodiment of the present invention. [0041] ---Fig. 18 is a circuit diagram for describing a modified example of the duplexer according to the second preferred embodiment of the present invention. [0042] ——Fig. 19 is a simplified frontal crosssectional view for describing a modified example of the duplexer according to the first preferred embodiment of the present invention. [0043] ---Fig. 20 is a circuit diagram for describing an example of a related-art duplexer. [0044] ——Fig. 21 is a graph illustrating a frequency characteristic of a transmission-side band filter of the related-art duplexer. [0045] ——Fig. 22 is a graph illustrating a frequency characteristic of a reception-side band filter of the related-art duplexer. [0046] ----Fig. 23 is a graph illustrating an isolation

Reference Numerals DETAILED DESCRIPTION OF PREFERRED EMBODIMENTS

characteristic of the related-art duplexer.

1	evlinder	dup lana
1	суттиаст	dubiesei

— la antenna terminal

—— 2 — antenna
3transmission-terminal
——4 reception terminal
5, 6 second inductance
7 first inductance
8 third inductance
—— 9 capacitor
11 LiNbO ₀ substrate
12 IDT cleatrode
12b Al electrode layer
—— 21 — duplexer
— 21a antenna terminal
21A transmission-side band filter
21B reception-side band filter
25 second inductance
— 27 first inductance
——————————————————————————————————————
33 cover member
34 acoustic surface wave element-chip
—— 41 — duplexer
42 multilayer substrate

43, 44 electrode land
45, 46 internal electrode
47a, 47b via hole electrode
48a, 48b via hole electrode
49, 50 internal electrode
51a, 51b via hole electrode
52, 53 terminal electrode
54 Linbo_ oubstrate
55 frame member
56 cover member
E1 to 86 serial arm resonator

Best Mode for Carrying Out the Invention

[0047] ——Hereinafter with reference to the drawings, the present invention will become apparent by way of describing be described with reference to specific preferred embodiments of the present invention.

<u>[0048]</u> — Fig. 1 is a circuit diagram for describing of a circuit configuration of a duplexer according to a first <u>preferred</u> embodiment of the present invention. It should be noted that an area surrounded by a dashed line corresponds to a duplexer area of this <u>preferred</u> embodiment in Fig. 1.

[0049] — A duplexer 1 includes an antenna terminal 1a.

Connected to the antenna terminal 1a are a transmission-side

band filter 1A and a reception-side band filter 1B. transmission-side band filter 1A is connected to a transmission terminal 3, and the reception-side band filter 1B is connected to a reception terminal 4. [0050] ——In the transmission-side band filter 1A, a plurality of surface acoustic wave resonators are connected to achievedefine a ladder circuit. That is, the transmission-side band filter 1A includes a plurality of serial arm resonators S1 to S3, each of which is composed of a-includes a surface acoustic wave resonator and parallel arm resonators P1 and P2. Inductances 5 and 6 are connected between the parallel arm resonators P1 and P2 and a ground potential. The inductances 5 and 6 constructdefine second inductances of the present invention. It should be noted that according to this preferred embodiment, the inductances 5 and 6 are constructed preferably defined by a wire bonding or a line arranged in the duplexer 1.

____On the other hand, the reception-side band filter 1B includes a configuration where a plurality of surface acoustic wave resonators that are connected to constructdefine a ladder circuit. Herein, a plurality of serial arm resonators S4 to S6 and a plurality of parallel arm resonators P3 and P4 are provided. Then, the serial arm resonator S6 in the last pole is connected in parallel with respect to an first inductance 7. With the connection of

the first inductance 7, in the reception-side band filter, an attenuation pole is formed provided on the low pass side of the pass band, and accordingly the increase in the attenuation of the reception-side band filter 1B on the low pass side of the pass band is achieved.

[0052] _______The first and second inductances 5 to 7 may be

[0052] —The first and second inductances 5 to 7 may be constructed defined by an external coil part component.

[0053] ____ In the meantime howeverHowever, the first and second inductances 5, 6 and 7 are preferably

constructed defined by at least one of the wire bonding and the line arranged in the duplexer. In that case, additional provision of external parts components, such as the coil part is component, are not necessary. Therefore, the first and second inductances 5 to 7 can be constructed without causing the increase in the number of parts provided without

 $\underline{\text{increasing the number of components of the duplexer }1}.$

____On the other hand, connected between the antenna terminal 1a and an antenna 2 is a third inductance 8. Then, connected between a connection point between the third inductance 8 and the antenna 2 and the ground potential is a capacitor 9. The third inductance 8 and the capacitor 9 are constructed by a part externallydefined by an external

<u>component</u> attached to the duplexer 1. Examples of such external <u>partcomponent</u> include a chip coil and a chip capacitor. [0055] ——According to this <u>preferred</u> embodiment, as described above, the first and second inductances 5 to 7 are eenstructeddefined by the wire bonding and/or the line in the duplexer, whereby the package area <u>ean beis</u> reduced to <u>about 90.25</u>% and the mounting area <u>ean beis</u> reduced <u>toto</u> about 80% <u>with respectas compared</u> to the related-art products.

[0056] ——Fig. 1(b) is a schematic frontal crosssectional view showing the electrode construction in the duplexer 1 described above, and a partportion of the electrode of the serial arm resonator S1 is schematically shown as the-a representative example of the electrode construction. The serial arm resonator S1 includes a 47° to 58° rotated, Y-cut, X-propagating LiNbO3 substrate 11 and an IDT electrode 12 formedprovided on the LiNbOn substrate 11. Then, the IDT electrode 12 includes a Ti foundation electrode layer foundation electrode layer formed through epitaxial growth on the LiNbO3 substrate and an Al electrode layer 12b formed through epitaxial growth on the Ti foundation electrode layer foundation electrode layer. Furthermore, the (111) face of the Al electrode layer, the (001) face or the (100) face of the Ti foundation electrode layer, and the (001) face of the LiNbO3 substrate are aligned in parallel. Therefore, as the IDT electrode 12 has a similar construction to that of the IDT electrode of the

surface acoustic wave elements described in Patent Document 1 mentioned above, the electric power resistance is superior. It should be noted that although Fig. 1 (b) schematically shows the electrode construction of the serial arm resonator S1, the other serial arm resonators S2, S3, and S4 to S6 and the parallel arm resonators P1 to P4 are constructed by using the IDT electrode with the similar crystal structure. Therefore, the duplexer 1 is has superior in the electric power resistance.

[0057] ——Next, a description will be given of a specific configuration of the duplexer 1 according to this preferred embodiment of the present invention.

[0058] ——Fig. 2 is a specific plan view of the duplexer according to the first <u>preferred</u> embodiment, and Fig. 3 is a plan cross-sectional view thereof at the intermediate height.

_____The duplexer 1 includes a package 31. The package 31 is enstructed by a multilayer package substrate composed of including an insulating ceramice, such as aluminum. That is, as shown in a schematic cross-sectional view of Fig. 4, the package 31 is a multilayer package substrate composed by laminatingincluding a plurality of of laminated insulating ceramic layers.

[0060] ——The package 31 includes an opening 31a openeda concave portion 31a that is open upward. As shown in Fig. 4, the concave portion 31a is structured while being closed by a cover member 32. Graphic representation for the cover member 32 is omitted in Fig. 2. In the concave portion 31a, an <u>surface</u> acoustic <u>surface</u> wave element chip 33 is accommodated as shown in Fig. 2.

[0061] ——The surface acoustic surface—wave element chip 33 is shown in a plan view of Fig. 5(a). The surface acoustic surface wave element chip 33 is constructed usingpreferably includes a substantially rectangular LiNbO3 substrate 11. As described above, according to the first preferred embodiment, as the LiNbO3 substrate 11, a 55° rotated, Y-cut LiNbO3 substrate is preferably used. [0062] ——Then, the IDT electrode with the crosssectional construction shown in Fig. 1(b) is formed provided on the LiNbO3 substrate 11 to formdefine the serial arm resonators S1 to S6 and the parallel arm resonators P1 to P4. In Fig. 5(a), the graphic representation for the electrode construction of the serial arm resonator and the parallel arm resonator is simplified, whereas Fig. 5(b) shows the electrode construction of the serial arm resonator S6 in a schematic plan view. That is, as shown in Fig. 5(b), the serial arm resonator S6 is a one terminal pair surface acoustic wave resonator including the IDT electrode 35 and reflectors 36 and 37 on both sides of the surface acoustic wave propagating direction of the IDT electrode 35.

[0063] ——It should be noted that each of other serial

arm resonators S3 and S5 and the parallel arm resonators P1 to P4 is similarly composed of a one terminal pair surface acoustic wave resonator by arranging reflectors on both sides in the directions of the surface acoustic wave propagating direction of the IDT electrode. On the other hand, as shown in Fig. 5(c), the serial arm resonator S2 includes an IDT electrode 38 to which a pair of IDT electrodes are connected and reflectors 39 and 40 arranged on both sides in the directions of the surface acoustic wave propagating direction of the IDT electrode 38. That is, the serial arm resonator S2 has a construction where includes two serial arm resonators S2a and S2b are connected. In a similar manner, the serial arm resonator S1 and the serial arm resonator S4 also have a construction whereincludes serial arm resonators S1a and S1b and serial arm resonators S4a and S4b that are respectively connected. [0064] In the meantime however, in the However, in

various preferred embodiments of the present invention, the serial arm resonator or the parallel arm resonator constructingdefining the ladder circuit may be composed of include a surface acoustic wave resonator having a single pole construction or a plural pole construction with the any suitable number of poles.

[0065] —As shown in Fig. 5 (a), formed on the LiNbO₃ substrate 11 are the serial arm resonators S1 to S6 and the

parallel arm resonators P1 to P4, which are provided on the LiNbO3 substrate 11, and are respectively electrically connected to constructdefine the transmission-side band filter 1A and the reception-side band filter 1B. That is, as shown in Fig. 1, in the transmission-side band filter 1A, the serial arm resonators S1 to S3 and the parallel arm resonators P1 and P2 are electrically connected to constructdefine a ladder circuit. In a similar manner, in the reception-side band filter 1B, the serial arm resonators S4 to S6 and the parallel arm resonators P1 and P2 are electrically connected to construct define a ladder circuit. [0066] ----Furthermore, according to the first preferred embodiment, the second inductances 5 and 6 are constructed defined by the bonding wire and the coil patterns in the package. To be more specific, as shown in Fig. 3, the inductances 5 and 6 are constructed defined by coil patterns 5a and 6a formedprovided at the intermediate height positions of the package 31 and bonding wires 41 and 42 shown in Fig. 4, and the like. Then, the first inductance 7 is constructeddefined by the bonding wire and the coil patterns in the package shown in Fig. 2. In this manner, as the coil patterns 5a, 6a, and 7a, and the bonding wires 41 and 42 provided inside the package, and the like are used, the first and second inductances 5, 6 and 7 can be constructed are provided without increasing the number of

partscomponents.

embodiment is not only superior in the electric power resistance, and but also is constructed by usinguses a 47° to 58° rotated, Y-cut, X-propagating LiNbO₃ substrate 11, whereby the out-of-band attenuation is sufficiently large and the isolation characteristic is satisfactory—as well. This will be described on the basis of specific emperimental examples.

____Each of the serial arm resonators S1 to S6 and the parallel arm resonators P1 to P4 is composed of the defined by the surface acoustic wave resonator having the IDT electrode of the above-mentioned construction formedprovided on the 55° rotated, Y-cut, X-propagating LiNbO3 substrate 11. It should be noted that the thickness of the Ti foundation electrode layer is set to about 10 nm and the thickness of the Al electrode layer is set to about 92 nm.

____Specifications of the serial arm resonators S1 to S6 and the parallel arm resonators P1 to P4 are shown in Tables 1 and 2 below. In the Tables 1 and 2 below, the number of the electrode fingers of the reflector, the duty ratio of the IDT electrode, the size of a gap between the IDT and the reflector, the cross width and log of the electrode fingers of the IDT electrode, and a wavelength $\frac{1}{12}$

are shown.

Table 1

	The number of reflector fingers	Duty ratio	Gap	Cross width	IDT log	λ
S1	15	0. 4	0. 5	40	140	2. 1743
P1	15	0. 4	0. 45	40	80	2. 3016
S2a	15	0. 4	0. 5	55	200	2. 1533
S2b	15	0. 4	0. 5	55	200	2. 1533
P2	15	0. 4	0. 45	40	80	2. 2957
S3a	15	0. 4	0. 5	40	160	2. 1743
S3b	15	0.4	0. 5	40	160	2. 1743

Table 2

	The number of reflector fingers	Duty ratio	Gap	Cross width	IDT log	λ
S4a	15	0. 4	0. 5	40	65	1. 9648
S4b	15	0. 4	0. 5	40	65	1. 9648
P3	15	0. 4	0. 45	65	70	2. 1146
S5	15	0. 4	0. 5	50	80	1. 9703
P4	15	0. 4	0. 45	55	70	2. 1146
S6	15	0. 4	0. 5	50	85	2, 0057

[0070] ——Then, the transmission-side band filter 1A and the reception-side band filter 1B are fabricated soconstructed such that the intermediate frequency of the transmission-side band filter 1A is set to about 1945 MHz and the intermediate frequency of the reception-side band filter 1B is set to about 2140 MHz. A coil pattern with the inductance of about 2.7 nH is formedprovided as the coil pattern to construct the second inductances 5 and 6 so that the inductance of about 3.3 nH is attained by the coil pattern and the bonding wire with the inductance of about 0.6 nH. Also, regarding the first inductance 7, the inductance value of the coil pattern is set to about 0.8 nH and the inductance value of the bonding wire the inductance value is set to about 1.2 nH, whereby the inductance value of the first inductance 7 is set to about 1.9 nH. [0071] ——The value of the third inductance 8 is set to about 3.3 nH and the capacity of the capacitor 9 is set to

about 1.3 pF. Frequency characteristics of the duplexer 1 thus fabricated_constructed_according to this preferred embodiment arewere measured. Figs. 6 to 8 show the results. Then, the pass band of the transmission-side band filter 1A is 1920 to 1980 MHz and the pass band of the reception-side band filter 1B is 2110 to 2170 MHz.

_____Fig. 6 shows a frequency characteristic of the transmission-side band filter 1A, Fig. 7 shows a frequency characteristic of the reception-side band filter 1B, and Fig. 8 shows the isolation characteristic of the duplexer. It should be noted that, the frequency characteristics on the lower sides in Figs. 6 and 7 represent the frequency characteristics in pass bands based on the right-hand side scale shown through magnification of the corresponding frequency characteristics.

that—in the transmission-side band filter 1A, the attenuation on the high pass side of the pass band (reception-side band) is about 47 dB, and it is understood that—the value is by—far largersubstantially greater than 40 dB as demand characteristics.required. Similarly, as is apparent from Figs. 7 and 8, it—is understood that—in the pass band of the reception-side band filter 1B, the attenuation of the isolation characteristic obtains—is at least about 48 dB.

That is, as is apparent from Figs. 6 to 8, it is understood that in the duplexer, not only the electric power resistance is increased, but also, the out-of-band attenuation, in is increased. In particular, the attenuation on the high pass side of the pass band of the transmission-side band filter 1A can be is significantly improved, and at the same time, the isolation characteristic can is also be significantly improved.

[0075] ——As described above, in the duplexer 1, the out-of-band attenuation and the isolation characteristic is significantly improved- because a LiNbO3 substrate with a cut angle falling in a range from about 47° to about 58° is used for the LiNbO3 substrate 11. This will be described on the basis of specific experimentexperimental examples. The characteristics of the above-described related-art product shown in Figs. 21 to 23 correspond to the characteristics of the duplexer similarly constructed as in the first preferred embodiment except that the cut angle of the LiNbO3 substrate is 64° and the serial arm resonators S1 to S3 and S4 to S6 and the parallel arm resonators P1, P2, P3, and P4 are constructed as shown in Tables 3 and 4 below. At this time, when the cut angle of the substrate is varied, it is of eourse-necessary to vary the values of the duty ratio, the cross width, and the likeother parameters with which optimal characteristics (characteristics at low loss and high

attenuation) can be obtained. Therefore, to conduct characteristic comparisoncomparisons in view of the cut angle, the optimal characteristics in the 55° rotated, Y-cut, X-propagating LiNbO: substrate and the optimal characteristics in the 64° rotated, Y-cut, X-propagating LiNbO3 substrate needmust be to-compared with each other. For this reason, the duty $ratio_{\tau}$ and the cross width $\frac{1}{\tau}$ and the like shown in Tables 1 and 2, with which the optimal characteristics can be are obtained in the 55° rotated, Ycut, X-propagating LiNbO3 substrate are different from the duty ratio, and the cross width, and the like shown in Tables 3 and 4, with which the optimal characteristics ean be-are obtained in the 64° rotated, Y-cut, X-propagating LiNbO3 substrate. Then, as described with reference to Figs. 21 to 23, in the duplexer 201, the pass band attenuation and the isolation characteristic of the transmission-side hand filter are not sufficiently large.

Table 3

	The number of reflector fingers	Duty ratio	Gap	Cross width	IDT log	λ
S1	14	0. 390	0. 5	60	196	2. 1450
P1	14	0. 347	0. 5	54. 3	92	2. 2525
S2a	14	0. 390	0. 5	32. 5	200	2. 1450
S2b	14	0. 390	0. 5	92	200	2. 1450
P2a	14	0. 347	0. 5	41. 9	90	2. 2526
P2b	14	0. 347	0. 5	41. 9	90	2. 2526
S3a	14	0. 390	0. 5	40	165	2. 1450
S3b	14	0. 390	0. 5	36	165	2. 1450

Table 4

	The number of reflector fingers	Duty ratio	Gap	Cross width	IDT log	λ
S4a	14	0. 389	0. 5	31. 5	125	1. 9559
S4b	14	0. 389	0. 5	35	125	1. 9559
S4c	14	0. 389	0. 5	40	125	1. 9559
P3	14	0. 361	0. 5	41. 2	114	2. 0896
S5	14	0. 390	0. 5	28	116	1. 9967
P4	14	0. 361	0. 5	41. 2	114	2. 0896
S6a	14	0. 390	0. 5	75	165	1. 9967
S6b	14	0. 390	0. 5	53	165	1. 9967

[0076] —On the other hand, for further comparison, a duplexer constructed as in according the preferred embodiment described above except that the cut angle of the LiNbO₃ substrate is 45° is fabricated constructed and the frequency characteristic is measured. Figs. 9 to 11 show the results.

_____Fig. 9 shows the frequency characteristic of a transmission-side band filter of a duplexer for the
<u>comparison_comparative</u> example, Fig. 10 shows the frequency characteristic of a reception-side band filter, and Fig. 11 shows the isolation characteristic. It should be noted that the frequency characteristics on the lower sides in Figs. 9 and 10 represent the frequency characteristics in pass bands based on the right-hand side scale shown through magnification of the corresponding frequency characteristics.

[0078] ______As is apparent from Figs. 9, when the LiNbO3 substrate with a cut angle of 45° is used, the attenuation

on the high pass side of the pass band the reception-side band filter reaches just above 40 dB, and it is slightly above 40 dB, and it is understood that the attenuation is lower as compared withto the duplexer 1 according to the preferred embodiment described above. Also, from Figs. 10 and 11, the isolation characteristic of the reception-side band filter is also slightly above 40 dB, and it is understood that the isolation characteristic is not sufficiently large.

[0079] ——As is apparent by comparing the result of the preferred embodiment described above with the result from the comparison comparative examples using the LiNbOa substrate with the cut angle of 45° shown in Figs. 9 to 11 and the result from the related-art examples using the LiNbO3 substrate with the cut angle of 64° described with reference to Figs. 20 to 23, when the rotation angle of the LiNbO3 substrate is set to about 55°, the out-of-band attenuation and the isolation characteristic may be effectively amelioratedare sufficiently large in the duplexer 1. Then, based on the experiments conducted by the inventors of the present invention, in the duplexer 1 described above, when the cut angle of the LiNbO3 substrate is set with in a range from about 47° to about 58°. satisfactory characteristics can be are obtained, as in the preferred embodiment described above.

[0080] ——As shown in Figs. 9 to 11, as the cut angle is smallerdecreased, the out-of-band attenuation cannot be set sufficiently large. This is because, as the cut angle is smallerdecreased, the insertion loss is increased, and an attenuation constant α is larger.increases. As the electromechanical coupling coefficient is too large, steepness cannot be obtained, thereby degrading the attenuation (the band selectivity is degraded). Therefore, in consideration with the change in characteristics due to the temperature, the-a sufficiently large out-of-band attenuation and isolation characteristic cannot be obtained. [0081] ---In addition, as the cut angle is smallerdecreased, an angle between the Y axis and a normal to the substrate becomes smalldecreases, and the epitaxial growth of electrode films is difficult. Therefore, the formation of the electrode with the high electric power resistance is also difficult. The lower limit of the cut angle whereat which the electrode films maycan be formed through the epitaxial growth is aroundabout 47° based on the experiences experiments conducted by the inventors of the present invention. That is, when the LiNbO3 substrate whose cut angle is smallerless than about 47° is used, it was impossible to form the electrode films through the epitaxial growth. Therefore, as described above, the lower limit of the cut angle for the LiNbO3 substrate is about 47°.

_____On the other hand, in consideration with the use temperature range of the duplexer, the upper limit of the cut angle for satisfyingwhich satisfies the attenuation and the isolation characteristic is about 58°. When the LiNbO₃ substrate whose cut angle is largergreater than about 58° is used, the out-of-band attenuation cannot be set sufficiently large. Therefore, for example, in the transmission-side band filter, the inductance element connected in parallel with respect to the serial arm resonators cannot be omitted.

that H denotes the thickness of the electrode and $\#\underline{\lambda}$ denotes the wavelength of the surface acoustic wave.

that—as the cut angle exceeds 40° to 60° and is further largerincreased, an electromechanical coupling coefficient K becomes small. Therefore, to enlarge the out-of-band attenuation in the neighborhood of the band, it has been thought that desirably, the cut angle is set to be large and the band width is set to be small. That is, in the related art, to enlarge the out-of-band attenuation, it has been thought that the larger the cut angle of the rotated, Y-cut LiNbO₃ substrate, the—are more desirable.

<u>nonesty</u>—Also, in the related art, it has been thought that when the rotated, Y-cut LiNbO₃ substrate is used, as the cut angle is <u>largerincreased</u>, the propagation loss α is <u>smallerdecreased</u>, whereby the insertion loss can be set smaller and at the same time the out-of-band attenuation can be <u>enlarged</u>increased.

That is, in-despite of the technical common knowledge of the related art wherein which it is desirable to set the cut angle as large as possible when the duplexer is constructed by using the rotated, Y-cut LiNbO3 substrate to enlarge the out-of-band attenuation, that is, the cut angle is desirably larger than about 60°, it is characterized in the present invention thatsets the cut

angle is set—to equal to or smallerless than about 58°.

Then, by setting the cut angle in the particular range from about 47° to about 58°, the electrode that is superior in the—electric power resistance can be formed, also furthermore provided, and, in addition, it is possible to set the out—of—band attenuation and the isolation characteristic to be sufficiently large.

[0087] ——Thus, according to the preferred embodiment described above, as the sufficient out-of-band attenuation can be is obtained, the number of the inductance elements used for ensuring the attenuation can be is reduced. That is, with the related-art duplexer shown in Fig. 20, while the inductance 205 is connected in parallel with respect to the serial arm resonator Sc in the transmission-side band filter 201A, it is possible to omit the inductance 205. Therefore, the downsizingsize of the duplexer can be achieved reduced. [0088] In the meantime howeverHowever, as in the preferred embodiment described above, the first inductance 7 is connected in parallel with respect to the serial arm resonator S6, and accordingly, the out-of-band attenuation may be further enlarged.increased. It should be noted that in the related art, even when the LiNbO3 substrate whose cut angle is largergreater than about 60°, in actual-the sufficient out-of-band attenuation cannot be obtained, and it is actually-impossible to omit the inductance 205

described above.

[0089] ---Fig. 13 is a circuit diagram for describing a duplexer according to a second preferred embodiment of the present invention. It should be noted that in Fig. 13 an area surrounded by a dashed line corresponds to a duplexer construction area of according to this preferred embodiment. [0090] ——A duplexer 21 includes an antenna terminal 21a. Connected to the antenna terminal 21a are a transmissionside band filter 21A and a reception-side band filter 21B. The transmission-side band filter 21A is connected to the transmission terminal 3, and the reception-side band filter 21B is connected to the reception terminal 4. The transmission-side band filter 21A and the reception-side band filter 21B respectively have the construction where theinclude five surface acoustic wave resonators that are connected to realize the define a ladder circuit similarly to the transmission-side band filter 1A and the receptionside band filter 1B of the first preferred embodiment. Therefore, the same partcomponents will be given of the same reference numerals and the description for the first preferred embodiment is to be incorporated herein. [0091] --- According to the second preferred embodiment, in the transmission-side band filter 21A, a second inductance 25 is connected between the parallel arm resonators P1 and P2 and the ground potential is a second

inductance 25. Herein, the second inductance 25 is constructed provided in the duplexer 21. [0092] ——The second inductance 25 may be eemposed of defined by the wire bonding or the line used in the duplexer 21. In the meantime howeverHowever, the second inductance 25 may be composed of defined by the coil partcomponent or the like as the part other suitable component, similar to the component externally attached to the duplexer 21. [0093] — Then, in In the reception-side band filter 21B, a first inductance 27 is connected in parallel with respected to the serial arm resonator S6 in the last pole. With the connection of the first inductance 27, in the reception-side band filter 21B, the attenuation pole is formed provided on the low pass side of the pass band. Accordingly, the increase in the attenuation of the reception-side band filter 21B on the low pass side of the pass band is achieved. [0094] ——The first inductance 27 may be composed ofdefined by the coil partcomponent or may be composed efdefined by the wire bonding or the line in the duplexer. [0095] ——In the duplexer 21-as-well, , the third inductance 8 and the capacitor 9 are connected between the antenna terminal 21a and the antenna 2-are-the-third inductance 8 and the capacitor 9, as in the case of the

first preferred embodiment.

in this preferred embodiment—also, when the first and second inductances 25 and 27 are composed of defined by at least one of the wire bonding and the line arranged in the duplexer, additional provision of the other coil part is components are not necessary-required.

Therefore without causing the increase in the number of parts, the first and second inductances 25 and 27 can be constructed are provided without increasing the number of parts components.

______According to this <u>preferred</u> embodiment, the duplexer 21 is composed of theincludes a 50° rotated, Y-cut, X-propagating LiNbO₃ substrate, the serial arm resonators S1 to S6 and the parallel arm resonators P1 to P4 are constructed in the same manner as in the case of the first <u>preferred</u> embodiment. Each of the serial arm resonators S1 to S6 and the parallel arm resonators P1 to P4 is composed of theincludes IDT electrodes having the electrode construction wherein which the Ti foundation electrode layer and the Al electrode layer are laminated. Therefore, a description of the construction of the IDT electrode will be omitted by incorporating the description of the electrode construction with reference to Fig. 1(b) in the first preferred embodiment.

[0098] — The duplexer 21 of the second <u>preferred</u> embodiment described above is fabricated inusing the

following procedure, and the frequency characteristic is measured.

[0099] ——The serial arm resonators S1 to S6 and the parallel arm resonators P1 to P4 are constructed as shown in Tables 5 and 6 below.

[0100] _____In anthe preferred embodiment described below, the serial arm resonators S1, S2, and S4 have a_double apole construction offincluding the serial arm resonators S1a and S1b, S2a and S2b, and S4a and S4b.

Table 5

	The number of reflector fingers	Duty ratio	Gap	Cross width	IDT log	λ
S1	15	0. 4	0. 5	44	120	2. 187421
P1	15	0. 4	0. 4	44	80	2. 322526
S2a	15	0. 4	0. 5	45	100	2. 160974
S2b	15	0. 4	0. 5	45	100	2. 160974
P2	15	0. 4	0. 4	44	80	2. 328572
S3a	15	0. 4	0. 5	44	200	2. 187421
S3b	15	0.4	0. 5	44	200	2. 187421

Table 6

	The number of reflector fingers	Duty ratio	Gap	Cross width	IDT log	λ
S4a	15	0. 4	0. 5	35	65	1. 958722
S4b	15	0. 4	0. 5	35	65	1. 958722
P3	15	0. 4	0. 45	50	90	2. 103972
S5	15	0. 4	0. 5	30	60	1. 964194
P4	15	0. 4	0. 45	45	70	2. 099018
S6	15	0. 4	0. 5	50	85	2. 003944

[0101] Then, the The second inductance 25 is composed of the defined by the bonding wire in the duplexer 21, and the inductance value is set to about 0.6 nH. The first inductance 27 is constructed defined by the coil pattern and the bonding wire formed-provided inside the duplexer 21. The inductance value of the coil pattern is set to about 0.8 nH and the inductance value of the bonding wire is set to about 1.2 nH. That is, the inductance 27 is configured to have the inductance value of about 2.0 nH. [0102] ——The inductance value of the inductance 8 externally attached is set to about 3.3 nH, and the electrostatic capacity of the capacitor 9 is set to about 1.3 pF. Frequency characteristics of the duplexer 21 constructed as described above are shown in Figs. 14 to 16. Fig. 14 shows a frequency characteristic of the transmission-side band filter of the duplexer 21, Fig. 15 shows a frequency characteristic of the reception-side band filter, and Fig. 16 shows the isolation characteristic. It

should be noted that the frequency characteristics on the lower sides in Figs. 14 and 15 represent the frequency characteristics in pass bands based on the right-hand side scale shown through magnification of the corresponding frequency characteristics.

[0103] ——As is apparent from Fig. 14, even when the LiNbO₃ substrate with a cut angle of 50° is used, as in the case of the first preferred embodiment, the attenuation on the high pass side of the pass band (reception-side band) of the transmission-side band filter ean be_is_set largerto a value greater than about 40 dB. Also, as is apparent from Figs. 15 and 16, the isolation characteristic in the reception-side band is also by far largersubstantially greater than 40 dB.

duplexer according to the second <u>preferred</u> embodiment. In the duplexer 21 too, as in the <u>case of the first preferred</u> embodiment, the second inductance can be <u>formedprovided</u> by <u>forming</u> a coil pattern 27a in the package 31. Also, by using a bonding wire 25a, the first inductance 25 can be constructed is provided. In this manner, by <u>composing providing</u> the second and first inductances 25 and 27 of the coil pattern and the bonding wire in the package <u>constructing of</u> the duplexer 21, the <u>downsizing size</u> of the duplexer 21 <u>can be achieved</u> is reduced without <u>causing the</u>

[0104] ——Fig. 17 is a schematic plan view of the

increaseincreasing in the number of partscomponents.

[0105] ——It should be noted that according to the second preferred embodiment, the first inductance 27 is connected in parallel with respect to the serial arm resonator S6 in the last pole of the reception-side band filter, but as shown in Fig. 18, the first inductance 27A may be connected in parallel with respect to the serial arm resonator S5 in the center.

[0106] ----Furthermore, according to the preferred embodiment described above, for achieving the impedance matching among the antenna, the transmission-side band filter, and the reception-side band filter, there is used a matching circuit where is provided in which an inductance is inserted between an antenna terminal and an antenna and also a capacitor is connected between the antenna and a ground. However, as long as the impedance matching among the antenna, the transmission-side band filter, and the reception-side band filter can be achieved, any matching circuit construction other than the matching circuit described above may be adopted.used. For example, a matching circuit where in which a capacitor is connected between an antenna terminal and an antenna and also-an inductance is connected between the antenna and a ground, or a matching circuit wherein which an inductance is simply connected between an antenna and a ground may also be adoptedused.

[0107] — Then, aA duplexer 41 as a modified example shown in Fig. 19 adopts the uses a similar package constructionconfiguration as that of the duplexer 1. In the meantime-howeverHowever, herein, a multilayer substrate 42 is used as a package member. FormedElectrode lands 43 and 44 are provided on the upper surface of the multilayer substrate 42-are electrode lands 43 and 44. The electrode lands 43 and 44 are electrically connected to internal electrodes 45 and 46 for inductance constructions arranged inside the multilayer substrate 42 via hole electrodes 47a and 47b so as to provide an inductance. In addition, the internal electrodes are connected to internal electrodes 49 and 50 for inductance constructions via hole electrodes 48a and 48b so as to provide an inductance. The internal electrodes 49 and 50 are connected to terminal electrodes 52 and 53 via hole electrodes 51a and 51b. In this manner, the inductance may be constructed provided inside the multilayer substrate 42, and a SAW chip constructed by using including an LiNbO3 substrate 54 constructed by using a flip chip bonding method may be mounted on the multilayer substrate 42. [0108] ——It should be noted that a frame member 55 made of the same material preferably is integrally provided on the upper surface of the multilaver substrate 42. Then, a cover member 56 for sealing the upper side of the frame member 55 is jointeddisposed on the upper surface of the

frame member 55.

[0109] While preferred embodiments of the present invention have been described above, it is to be understood that variations and modifications will be apparent to those skilled in the art without departing the scope and spirit of the present invention. The scope of the present invention, therefore, is to be determined solely by the following claims.